



**Figure S1.** Length dependence of the nanowire inverse-transconductance. The inverse-transconductance,  $R_m=1/g_m$ , was calculated from the linear scale transconductance,  $g_m$ , at bias voltage of 10 mV and scales linearly with channel length from 190 nm to 1  $\mu\text{m}$ . The linear increase is consistent with the charge control model at low bias,  $\mu = \frac{g_m}{V_{ds}} \cdot \frac{L^2}{C}$ , since the gate capacitances per unit length,  $C/L = 800 \text{ aF}/\mu\text{m}$ , is a constant in these devices (i.e., the devices have the same dielectric thickness and top gate geometry). The average mobility determined from these data is  $640 \text{ cm}^2/\text{V}\cdot\text{s}$ .